

# 1 *In situ* intercalation strategies for device-quality hybrid inorganic-organic 2 self-assembled quantum wells

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7 Thin films of self-organized quantum wells of inorganic-organic hybrid perovskites of  
8  $(C_6H_9C_2H_4NH_3)_2PbI_4$  are formed from a simple intercalation strategy to yield well-ordered  
9 uniform films over centimeter-size scales. These films compare favorably with traditional  
10 solution-chemistry-synthesized thin films. The hybrid films show strong room-temperature  
11 exciton-related absorption and photoluminescence, which shift with fabrication protocol. We  
12 demonstrate the potential of this method for electronic and photonic device applications. © 2009  
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14 The large family of metal halide-based inorganic-organic  
15 hybrid perovskite crystals has attracted much attention be-  
16 cause of their unique flexibility in structure and electro/  
17 optical properties.<sup>1-3</sup> Especially of interest are two-  
18 dimensional (2D) layered perovskites, generally in the form  
19 of  $(R-NH_3)_2MX_4$  ( $R$  is organic group,  $M=Pb$ ,  $Sn$ , and  $Ge$ ,  
20 and  $X=Br$ ,  $Cl$  and  $I$ ), regarded as a naturally self-assembled  
21 multiple quantum-well (QW) structure where sheets of ex-  
22 tended  $[MX_6]$  octahedra and organic spacer layers are alter-  
23 nately stacked. These hybrids show large exciton binding  
24 energies enabling QW excitons to be observed even at room  
25 temperature due to quantum mechanical as well as dielectric  
26 confinement effects.<sup>1-4</sup> However, usage of these QW hybrids  
27 in electronic and optoelectronic devices is limited by the lack  
28 of appropriate methodologies to generate uniform and highly  
29 ordered thin films.<sup>5</sup> This is challenging since solution pro-  
30 cessing and spin-coating techniques are constrained in ob-  
31 taining well-ordered films with good uniformity. Although  
32 methods such as layer-by-layer deposition<sup>6</sup> and Langmuir-  
33 Blodgett techniques<sup>7</sup> have been explored, potential applica-  
34 tions demand much simpler and more reliable techniques.

35 Here we establish a much simpler but efficient technique  
36 to prepare highly ordered and strongly emitting lead iodide-  
37 based self-assembled QW sheets, formed of cyclohexenyl  
38 ethyl ammonium lead iodide  $(C_6H_9C_2H_4NH_3)_2PbI_4$  (CHPI).  
39 A very general method is adopted to intercalate organic guest  
40 moieties into the vacuum deposited host, lead iodide ( $PbI_2$ ),  
41 [Fig. 1(a)]. The evolution of the intercalation process is di-  
42 rectly tracked both structurally and optically, showing im-  
43 proved performance over thin films produced from CHPI  
44 single crystals. We demonstrate this technique for potential  
45 applications in photonic/electronic device fabrication.

46 The 2-(1-cyclohexenyl) ethyl ammonium iodide,  
47  $C_6H_9C_2H_4NH_3I$  (CHI) organic moiety is dissolved in a 1:6  
48 mixture of isopropyl alcohol:toluene.  $PbI_2$  thin films of vari-  
49 able thickness are thermally evaporated onto glass/silicon  
50 substrates and the resulting films are dipped for controlled  
51 times into CHI solution to obtain intercalated CHPI films.  
52 For comparison, we also prepare thin films from single crys-

53 tals of CHPI, according to the procedure reported in Ref. 8  
54 by redissolving the crystals in acetonitrile solution and spin  
55 coating thin films onto glass/silicon substrates. Films are  
56 characterized both structurally by x-ray diffraction (XRD)  
57 and atomic force microscopy (AFM), and optically by ab-  
58 sorption and photoluminescence (PL).  
59

60 The intercalation process inserts appropriately sized  
61 guest moieties into the empty spaces within a crystalline  
62 host. This is most favorably achieved for layered structures  
63 since there is greater flexibility in adjusting the interlayer  
64 separations. The kinetics and layer formation during interca-  
65 lation are typically dependent on the nature and shape of the  
66 guest moiety, the concentration of guest molecules, and the  
67 solvent used.<sup>9</sup> The CHPI thin films processed from both in-  
68 tercalation as well as spin coating are subjected to extensive  
69 optical and structural characterization to ascertain the depen-  
70 dence on fabrication parameters.

71 The XRD patterns imply that the bulk polycrystalline  
72  $PbI_2$  2D layers appears to be weakly organized with the  $c$   
73 axis orientated perpendicular to the substrate, and plane  
74 separation  $d=6.78$  Å [Fig. 1(b) (i)]. We track the intercala-  
75 tion process through XRD of the films for increasing inter-

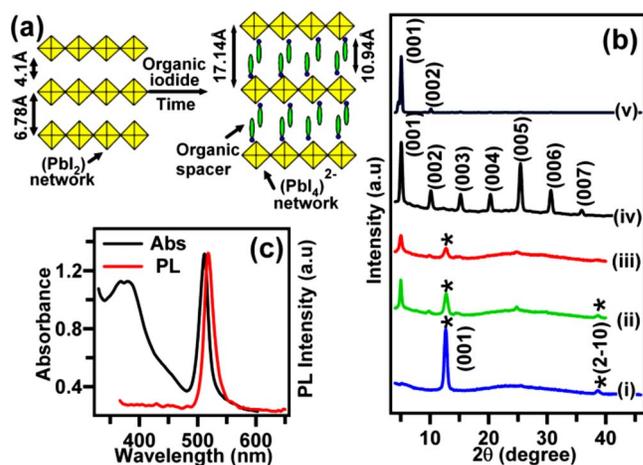


FIG. 1. (Color online) (a) Schematic intercalation process for CHPI. (b) XRD diffraction patterns of (i) pure  $PbI_2$  film, (ii)–(iv) intercalated CHPI films for intercalation durations of 1, 2, and 10 s, respectively, and (v) spin-coated CHPI film. \* indicates  $PbI_2$  diffraction peaks. (c) UV-visible absorption and PL of the intercalated thin CHPI film.

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76 calation times up to 10 s [Fig. 1(b) (ii)–(iv)]. Within 1 s of  
 77 intercalation time, the XRD pattern starts to show a new  
 78 (001) diffraction peak at  $2\theta=5.075^\circ$ , indicating the substan-  
 79 tial enhancement in layer-to-layer distance, with  $d_{(001)}$   
 80 = 17.4 Å. Here the edge-sharing layered  $\text{PbI}_3$  octahedra turn  
 81 into layers of corner-sharing  $\text{PbI}_6$  octahedra separated by bi-  
 82 layers of organic moieties [Fig. 1(a)].<sup>10,11</sup> However, the pres-  
 83 ence of host  $\text{PbI}_2$  [Fig. 1(b) (ii) and (iii)] suggests that the  
 84 intercalation process is not fully complete. After 10 s of in-  
 85 tercalation time, the XRD pattern shows narrow peaks of  
 86 higher diffraction orders, related to (00*l*) (*l*=2,3,4,...)  
 87 CHPI crystal planes, with no traces of host  $\text{PbI}_2$ . Therefore,  
 88 these XRD studies clearly show that  $\text{PbI}_2$  molecules com-  
 89 pletely react with the organic moieties, which penetrate from  
 90 the solution, and the resultant hybrid is self-organized and  
 91 highly crystalline in nature. Measurements by AFM of the  
 92 top film surface (not shown here) show that intercalation has  
 93 little or no effect on the surface quality. Comparable thin  
 94 films from resuspension of CHPI crystals were also fabri-  
 95 cated by spin coating giving the XRD in Fig. 1(b) (v). The  
 96 weaker higher-order diffraction peaks observed for this spin-  
 97 cast film, as well as their rougher surfaces, indicate that the  
 98 intercalated films are indeed of much higher quality. Hence  
 99 this intercalation process is an effective strategy to form uni-  
 100 form and highly oriented CHPI films from  $\text{PbI}_2$  and should  
 101 be more generally applicable for all inorganic-organic hybrid  
 102 perovskites, provided that the intercalation time, concentra-  
 103 tion of the organic solution, and the film thickness are opti-  
 104 mized.

105 Optical properties also reveal the structural organization  
 106 of these hybrid layered structures for different fabrication  
 107 conditions. In general, these compounds are self-organized  
 108 “quantum-well” structures, in which a 2D lead iodide semi-  
 109 conductor layer and an organic moiety layer are alternately  
 110 stacked. Due to the low dimensionality of the semiconductor  
 111  $\text{PbI}$  network, these hybrids exhibit strong room-temperature  
 112 excitons with large binding energies of about 200 meV, re-  
 113 sulting from quantum confinement and enhanced dielectric  
 114 confinement effects.<sup>1–5</sup> Figure 1(c) shows typical absorption  
 115 and PL spectra of intercalated CHPI films. Both spin coated  
 116 as well as intercalated CHPI films show relatively narrow  
 117 (full width at half maximum  $\sim 16$  nm) and strong excitonic  
 118 absorption (at 512 nm) and PL (at 517 nm) at room tempera-  
 119 ture. Figures 2(a) and 2(b) show the absorption and PL spec-  
 120 tra of intercalated films of various thicknesses, with constant  
 121 intercalation time of 10 s. Both absorption and PL spectra  
 122 show significant thickness dependence, with the spectral  
 123 peaks shifting in *opposite* directions. The spectral separation  
 124 between maximum absorption and PL (the Stokes shift) in-  
 125 creases from 5 to 18 nm as the thickness increases from 40 to  
 126 350 nm. The XRD patterns of these samples [Fig. 2(c)] show  
 127 the persistent presence of higher-order (00*l*) diffraction peaks  
 128 indicating that the layer stacking along the *c* axis is uniform  
 129 throughout the film. However for films more than 130 nm  
 130 thick, the appearance of a weak diffraction peak at  $12.5^\circ$   
 131 related to  $\text{PbI}_2$  suggests that the intercalation process does  
 132 not fully complete within 10 s. Since further structural de-  
 133 velopments are not observed, possibilities such as formation  
 134 of bilayers of inorganic/organic entities<sup>12</sup> and/or distortion of  
 135 the 2D network can be ruled out. The extra Stokes shift could  
 136 thus be due to either distorted bond angles within  $(\text{PbI}_6)^{4-}$

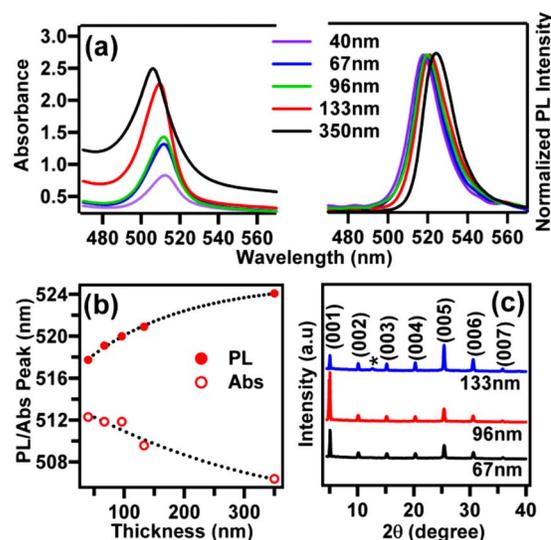


FIG. 2. (Color online) (a) Absorption and normalized PL spectra of intercalated CHPI films of different thicknesses. Intercalation time is 10 s for all the films. (b) PL and absorption spectral peaks vs film thickness. (c) XRD of CHPI intercalated films of different thickness. \* indicates  $\text{PbI}_2$  diffraction peaks.

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octahedra<sup>13</sup> or due to the low-level presence of unreacted  
 lead iodide impurities.

To examine the intercalation process in real time, we  
 perform *in situ* transmission measurements [Fig. 3(a)] with a  
 time interval of 70 ms. We extract here the transmission at  
 the CHPI excitonic absorption peak (510 nm) for two films  
 of thicknesses 67 and 350 nm. Imaging the transmission  
 spectra versus time [Fig. 3(b)] shows the smooth evolution  
 of the process. As seen from Fig. 3(a), the intercalation pro-  
 cess follows a double exponential behavior independent of  
 thickness: a fast initial process (0.1–0.4 s) producing attenu-  
 ation of up to 40%, followed by a slower (5–8 s) saturation  
 of the intercalation. The initial drop in transmission is as-  
 cribed to the immediate increase in reflectivity of the upper

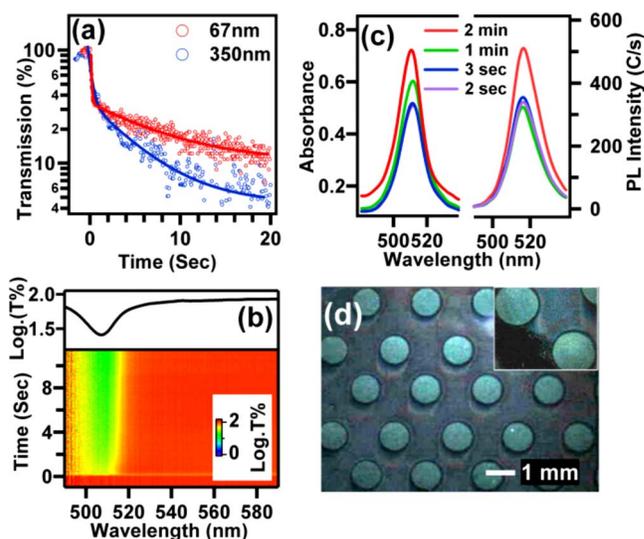


FIG. 3. (Color online) (a) Transmission vs intercalation time of CHPI films, monitored at 510 nm absorption maximum. Solid lines are double exponential fits. (b) Transmission spectra vs intercalation time of 67-nm-thick CHPI film. (c) Absorption and PL spectra of 67-nm-thick intercalated CHPI film for increasing intercalation time, and (d) microscope reflection image of patterned CHPI films on Si substrate. Inset is magnified view.

151 surface on commencement of intercalation, while the slower  
152 changes tracks the progression of the intercalation front  
153 through the sample. This agrees with the high optical density  
154 per layer of the CHPI which, in order to observe strong ex-  
155 citonic features, needs only tens of self-assembled layers<sup>6</sup> to  
156 saturate the optical features. This is further evident from the  
157 absorption and PL spectra plots of a 67-nm-thick film, dis-  
158 played at selected intercalation times [Fig. 3(c)].

159 For practical application, it is essential to establish the  
160 suitability of this technique for potential use in fabricating  
161 microscale photonic/electronic devices, compatible with  
162 lithographic techniques<sup>14</sup> and focused ion/laser beam writ-  
163 ing. Currently such experiments are ongoing. We exemplify  
164 the templated growth of millimeter-scale structures [Fig.  
165 3(d)], where a template comprised of circular apertures was  
166 used as a mask to deposit PbI<sub>2</sub> pillars for intercalation. As  
167 seen from the microscopic images, these structures are uni-  
168 form over a large scale and are highly luminescent and with  
169 less than 5 nm roughness (which was confirmed from AFM  
170 results, not shown here). Efforts are currently underway in  
171 our laboratories to fabricate micron-scale pillar structures.

172 In conclusion, we demonstrate a simple approach to  
173 fabricating high-quality and highly luminescent hybrid  
174 inorganic-organic self-assembled QW structures. We show  
175 how the optical and structural properties are robust, and that  
176 the intercalation process is efficient for further potential us-  
177 age in optoelectronic applications. These hybrid films have  
178 highly ordered stacking over the substrate with good unifor-  
179 mity over large areas, and show strong and narrow excitonic  
180 absorption and photoluminescence. We establish the poten-  
181 tial of this method for fabricating micron-scale devices. Fur-  
182 ther progress using this simple effective technique is aimed

toward device applications such as strongly coupled 183  
microcavities.<sup>15</sup> 184

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partment of Chemistry, MDS University, Ajmer (India), who 190  
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<sup>1</sup>D. B. Mitzi, C. A. Field, W. T. A. Harrison, and A. M. Guloy, *Nature* 192  
(London) 369, 467 (1994). 193

<sup>2</sup>T. Ishihara, J. Takahashi, and T. Goto, *Phys. Rev. B* 42, 11099 (1990). 194

<sup>3</sup>T. Ishihara, J. Takahashi, and T. Goto, *Solid State Commun.* 69, 933 195  
(1989). 196

<sup>4</sup>E. A. Muljarov, S. G. Tikhodeev, N. A. Gippius, and T. Ishihara, *Phys.* 197  
*Rev. B* 51, 14370 (1995). 198

<sup>5</sup>C. R. Kagan, D. B. Mizi, and K. Chondroudis, *Science* 286, 945 (1999). 199

<sup>6</sup>T. Matsui, A. Yamaguchi, Y. Takeoka, M. Rikukawa, and K. Sanui, *Chem.* 200 AQ:  
*Commun. (Cambridge)* 2002, 1094. 201 #3

<sup>7</sup>D. B. Mitzi, *Chem. Mater.* 13, 3283 (2001). 202 AQ:

<sup>8</sup>G. Vijaya Prakash, K. Pradeesh, R. Ratnani, K. Saraswat, M. E. Light, and 203 #4  
J. J. Baumberg, "■," *J. Phys. D: Appl. Phys.* (to be published). 204

<sup>9</sup>E. Ruiz-Hitzky, in *Functional Hybrid Materials*, edited by P. G. Romero 205 AQ:  
and C. Sanchez (Wiley, Weinheim, 2004) pp. 15–49. 206 #5

<sup>10</sup>U. Müller, *Inorganic Structural Chemistry* (Wiley, Chichester, 1993), 207  
p. 165. 208

<sup>11</sup>D. G. Billing and A. Lemmerer, *Acta Crystallogr., Sect. C: Cryst. Struct.* 209  
*Commun.* 62, m269 (2006). 210

<sup>12</sup>Y. Takeoka, M. Fukasawa, T. Matsui, K. Kikuchi, M. Rikukawa, and K. 211  
Sanuia, *Chem. Commun. (Cambridge)* 2005, 378. 212

<sup>13</sup>Z. Xu, D. B. Mitzi, C. D. Dimitrakopoulos, and K. R. Maxcy, *Inorg.* 213  
*Chem.* 42, 2031 (2003). 214

<sup>14</sup>Z. Y. Cheng, Z. Wang, R. B. Xing, Y. C. Han, and J. Lin, *Chem. Phys.* 215  
*Lett.* 376, 481 (2003). 216

<sup>15</sup>C. E. Finlayson, G. Vijaya Prakash, and J. J. Baumberg, *Appl. Phys. Lett.* 217  
86, 041110 (2005). 218

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